

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: MAJIMA et al.

Examiner: Le, Dung Anh

Serial No.: 09/890,550

Group No.: 2818

Filed: January 14, 2002


Title: POROUS SILICON CARBIDE SINTER AND SILICON CARBIDE-METAL  
COMPOSITE THAT ARE OPTIMAL FOR A WAFER GRINDER TABLE

#10  
D. Scott  
10-2502

RESPONSE TO RESTRICTION REQUIREMENT

CERTIFICATE OF FACSIMILE TRANSMISSION

I hereby certify that this correspondence is being transmitted  
to the Commissioner for Patents, Washington, DC 20231,  
via facsimile (fax no. 703-872 9318) on October 11, 2002.

  
Mark D. Passler Reg No. 40,764

VIA FACSIMILE (703 872 9318)  
Tech Center 2800

Commissioner for Patents  
Washington, D.C. 20231

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OCT 11 2002

Sir:

TECHNOLOGY CENTER 2800

This response is in reply to a restriction requirement set forth in the Office Action dated  
September 13, 2002, in the above-identified application, with a one month shortened statutory  
period, making a response due on or before October 13, 2002. This response is timely filed.

REMARKS

In the above-identified Office Action, the Examiner has issued a restriction requirement  
and requires election of one of the following species under 35 U.S.C. § 121:

Group I: Claims 20-27, 29-40 and 43-46, drawn to a semiconductor device, classified  
in class 25; or

Group II: Claims 28 and 41-42, drawn to a process of making a semiconductor  
device, classified in class 438, and subclass 409.